

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	1473	(anneal\$4 heat\$3 themal\$3) with (oxynitride)	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/09 12:45
L2	1160	1 and (anneal\$4 heat\$3 themal\$3 oxynitride) with temperature	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/09 12:38
L3	463	2 and (anneal\$4 heat\$3 themal\$3 oxynitride temperature) with (ambient atmosphere ratio concentration) with (nitrogen oxygen)	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/09 12:34
L4	232	3 and (anneal\$4 heat\$3 themal\$3 oxynitride temperature ambient atmosphere ratio concentration nitrogen oxygen) with dielectric	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/09 12:34
L5	130	4 and ( oxynitride nitrogen oxygen) with thickness	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/09 12:34
L6	726	2 and (anneal\$4 heat\$3 themal\$3 oxynitride temperature) with (ambient atmosphere ratio concentration) with (nitrogen oxygen)	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/09 12:33
L7	726	6 and (anneal\$4 heat\$3 themal\$3 oxynitride temperature) with (ambient atmosphere ratio concentration) with (nitrogen oxygen)	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/09 12:34
L8	353	7 and (anneal\$4 heat\$3 themal\$3 oxynitride temperature ambient atmosphere ratio concentration nitrogen oxygen) with dielectric	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/09 12:40

L9	216	8 and (oxynitride nitrogen oxygen) with thickness	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/09 12:35
L10	237	8 and (oxynitride nitrogen oxygen) with thickness	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/09 12:38
L11	140	10 and (nitrogen oxygen) with concentration	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/09 12:35
L12	179	10 and (nitrogen oxygen) with (concentration ratio "%" percent)	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/09 12:36
L13	114	12 and ( oxygen) with (concentration ratio "%" percent)	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/09 12:36
L14	114	13 and oxynitride	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/09 12:38
L15	35	14 and (anneal\$4 heat\$3 themal\$3) near\$ oxynitride	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/09 12:39
L16	31	15 and ( ambient atmosphere) with (nitrogen oxygen)	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/09 12:40
L17	30	15 and ( ambient atmosphere) near\$ (nitrogen oxygen)	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/09 12:40
L18	388	(anneal\$4 heat\$3 themal\$3) with (oxynitride) with substrate	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/09 12:45
L19	302	18 and (anneal\$4 heat\$3 themal\$3 oxynitride) with temperature	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/09 12:46

L20	20	18 and (anneal\$4 heat\$3 thema\$3 oxynitride) with temperature with minute	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/09 12:46
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